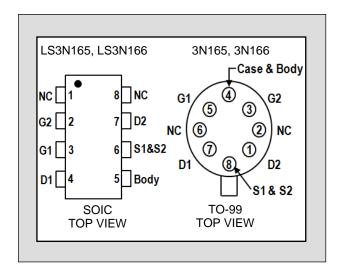


Twenty-Five Years Of Quality Through Innovation

FEATURES					
VERY HIGH INPUT IMPEDANCE					
HIGH GATE BREAKDOWN					
ULTRA LOW LEAKAGE					
LOW CAPACITANCE					
ABSOLUTE MAXIMUM RATINGS (NOTE 1)					
(T _A =25°C unless otherwise noted)					
Drain-Source or Drain-Gate Voltage (NOTE 2)					
3N165	40 V				
3N166	30 V				
Gate-Gate Voltage	±80 V				
Drain Current (NOTE 2)	50 mA				
Storage Temperature	-55°C to +150°C				
Operating Temperature	-55°C to +150°C				
Lead Temperature (Soldering, 10 sec.)	+300°C				
Power Dissipation (One Side)	300 mW				
Total Derating above 25°C	4.2 mW/°C				

LS/3N165, LS/3N166

MONOLITHIC DUAL P-CHANNEL ENHANCEMENT MODE **MOSFET**

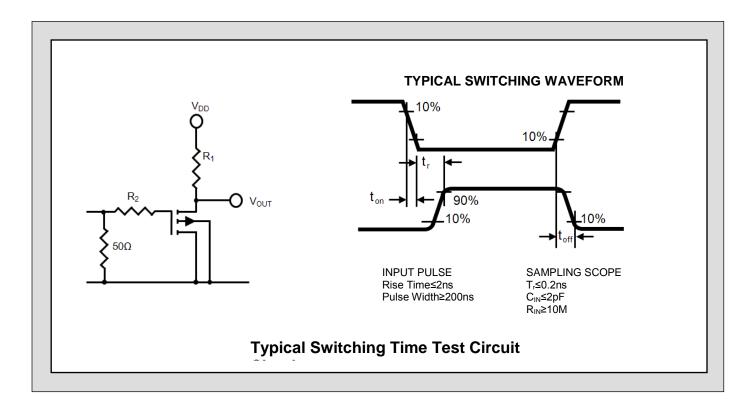


ELECTRICAL CHARACTERISTICS (T_A=25°C and V_{BS}=0 unless otherwise noted)

		3N165 & LS3N165 & LS3N166								
SYMBOL	CHARACTERISTIC	MIN	MAX	MIN	MAX	UNITS	CONDITIONS			
I _{GSSR}	Gate Reverse Leakage Current		10		100		V _{GS} =40V			
I _{GSSF}	Gate Forward Leakage Current		-10		-100		V _{GS} =-40V			
			-25			pА	T _A =+125°C			
I _{DSS}	Drain to Source Leakage Current		-200		-200		V _{DS} =-20 V, V _{GS} =V _{BS} =0V			
I _{SDS}	Source to Drain Leakage Current		-400		-400		V _{SD} =-20 V, V _{GD} =V _{DB} =0V			
I _{D(on)}	On Drain Current	-5	-30	-5	-30	mA	V _{DS} =-15V	V _{GS} =-10 V	V _{SB} =0V	
$V_{GS(th)}$	Gate Source Threshold Voltage	-2	-5	-2	-5	V	V _{DS} =-15V	I _D =-10μA	V _{SB} =0V	
$V_{GS(th)}$	Gate Source Threshold Voltage	-2	-5	-2	-5	V	$V_{DS}=V_{GS}$	I _D =-10μA	V _{SB} =0V	
r _{DS(on)}	Drain Source ON Resistance		300		300	ohms	V _{GS} =-20V	I _D =-100μA	V _{SB} =0V	
g fs	Forward Transconductance	1500	3000	1500	3000	μS	V _{DS} =-15V	I _D =-10mA	f=1kHz	
gos	Output Admittance		300		300	μS		V_{SB} =0 V		
C _{lss}	Input Capacitance		3.0		3.0					
C _{rss}	Reverse Transfer Capacitance		0.7		1.0	pF	V_{DS} =-15 V	$I_D=-10mA$	f=1MHz	
Coss	Output Capacitance		3.0		3.0		(<u>NOTE 3</u>)	V _{SB} =0V		
R _E (Y _{Is})	Common Source Forward	1200				μS	V _{DS} =-15V	I _D =-10mA	f=100MHz	
	Transconductance						(<u>NOTE 3</u>)	V _{SB} =0V		

MATCHING CHARACTERISTICS 3N165

		LIMITS							
SYMBOL	CHARACTERISTIC	MIN.	MAX.	UNITS	CONDITIONS				
G _{fs1} /G _{fs2}	Forward Transconductance Ratio	0.90	1.0		V _{DS} =-15V	I _D =-500 μA	f=1kHz	V _{SB} =0V	
V _{GS1-2}	Gate Source Threshold Voltage Differential		100	mV	V _{DS} =-15V	I _D =-500 μA	V _{SB} =0V		
$\Delta V_{GS1-2}/\Delta T$	Gate Source Threshold Voltage Differential		100	μV/ºC	V _{DS} =-15V	I _D =-500 μA	V _{SB} =0V		
	Change with Temperature				T _A =-55°C to	o = +125°C			



NOTES:

- 1. MOS field effect transistors have extremely high input resistance and can be damaged by the accumulation of excess static charge. To avoid possible damage to the device while wiring, testing, or in actual operation, follow these procedures:
 To avoid the build-up of static charge, the leads of the devices should remain shorted together with a metal ring except when being tested or used. Avoid unnecessary handling. Pick up devices by the case instead of the leads. Do not insert or remove devices from circuits with the power on, as transient voltages may cause permanent damage to the devices.
- 2. Per transistor.
- 3. For design reference only, not 100% tested.

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. These are stress ratings only and functional operation of the device at these or any other conditions above those indicated in the operational sections of the specifications is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

Linear Integrated Systems (LIS) is a 25-year-old, third-generation precision semiconductor company providing high-quality discrete components. Expertise brought to LIS is based on processes and products developed at Amelco, Union Carbide, Intersil and Micro Power Systems by company President John H. Hall. Hall, a protégé of Silicon Valley legend Dr. Jean Hoerni, was the director of IC Development at Union Carbide, co-founder and vice president of R&D at Intersil, and founder/president of Micro Power Systems.